

**AMENDMENT UNDER 37 C.F.R § 1.116  
EXPEDITED PROSECUTION - ART GROUP 1795**

03500.518677

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	)	
	:	Examiner: Anca Eoff
SHOJI SHIBA, ET AL.	)	
	:	Group Art Unit: 1795
Application No.: 10/577,218	)	
	:	Confirmation No.: 3411
Filed: April 26, 2006	)	
	:	
For: PHOTSENSITIVE RESIN	)	
COMPOSITION, METHOD OF	:	
FORMING LEVEL DIFFERENCE	)	
PATTERN USING THE	:	
PHOTSENSITIVE RESIN	)	
COMPOSITION, AND METHOD	:	
OF PRODUCING INK JET HEAD	)	Date: December 16, 2008

DO NOT ENTER: /A.E./

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

12/22/2008

AMENDMENT AFTER FINAL REJECTION

Sir:

a) Introductory Comments:

In response to the final Official Action dated September 18, 2008, kindly  
amend the above-identified application as follows.